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Baptiste Neil, Lamine Saadi, Louis Fensterbank, Clément Chauvier. Organopotassium-Catalyzed Silylation of Benzylic C(sp3)–H Bonds. Angewandte Chemie International Edition, 2023, 62 (31), pp.e202306115. 10.1002/anie.202306115. hal-04197394

HAL Id: hal-04197394 https://hal.sorbonne-universite.fr/hal-04197394

Submitted on 6 Sep 2023

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How to cite: Angew. Chem. Int. Ed. **2023**, 62, e202306115 doi.org/10.1002/anie.202306115

Organopotassium-Catalyzed Silylation of Benzylic C(sp³)-H Bonds

Baptiste Neil, Lamine Saadi, Louis Fensterbank, and Clément Chauvier*

Abstract: Benzylsilanes have found increasing applications in organic synthesis as bench-stable synthetic intermediates, yet are mostly produced by stoichiometric procedures. Catalytic alternatives based on the atomeconomical silylation of benzylic $C(sp^3)$ —H bonds remain scarcely available as specialized directing groups and catalytic systems are needed to outcompete the kinetically-favored silvlation of $C(sp^2)$ -H bonds. Herein, we describe the first general and catalytic-in-metal undirected silylation of benzylic $C(sp^3)$ -H bonds under ambient, transition metal-free conditions using stable tert-butyl-substituted silyldiazenes (tBu-N=N-SiR₃) as silicon source. The high activity and selectivity of the catalytic system, exemplified by the preparation of various mono- or gem-bis benzyl(di)silanes, originates from the facile generation of organopotassium reagents, including tert-butylpotassium.

Introduction

The advent of catalytic hydrosilylation over the last fifty years has arguably revolutionized the field of organosilicon chemistry by providing a direct and scalable entry to alkylsilanes through the insertion of unsaturated compounds (e.g. alkenes) into the Si–H bond of hydrosilanes.^[1] Since then, numerous applications have emerged both in organic synthesis and in material science, including the manufacture of hybrid organic–inorganic silicone polymers. However, the preparation of some valuable alkylsilanes such as primary benzylsilanes, which are important synthetic intermediates,^[2] is precluded by hydrosilylation and therefore requires other strategies to be devised.

To date, benzylsilanes have mainly been prepared by stoichiometric $C(sp^3)$ —Si bond formation upon coupling benzyllithium or benzylic Grignard reagents and chlorosilanes. Although various catalytic cross-coupling technologies have also emerged to assemble benzylsilanes through C—C bond formation (e.g. between arylhalides and α -metalated

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© 2023 The Authors. Angewandte Chemie International Edition published by Wiley-VCH GmbH. This is an open access article under the terms of the Creative Commons Attribution License, which permits use, distribution and reproduction in any medium, provided the original work is properly cited. silvlmethane, R₃SiCH₂-M), [3] all these approaches require extensive pre-functionalization of the coupling partners. Such functional group manipulations could in principle be obviated by the direct and atom-economical C(sp3)-H silylation of widely available alkylarenes. However, its practical implementation poses considerable challenge because of the weak acidity of this bond that usually gets activated at a much slower rate than arene $C(sp^2)$ -H bonds. As a consequence, though innovative catalytic silylation of $C(sp^3)$ -H bonds have been reported, [4] they remain generally limited compared to their $C(sp^2)$ -H counterparts.[5]

In the stoichiometric realm, selective metalation/silylation at the benzylic position has recently been achieved with strong Brønsted bases and chlorosilanes. [6] In this regard, the bimetallic mixed Li/K amide (Scheme 1A) reported by O'Shea and co-workers still constitute the state-of-the-art system for the selective realization of challenging lateral metalations. Catalytic alternatives, which benefit from enhanced atom-economy compared to the s-block metalbased approaches, lack generality as benzylic silvlation only occurs selectively when proper directing groups (DG) are installed on the arene core. To date, only alkylpyridines^[7] or methylarenes bearing ortho-pyridyl, [8] amino [9] and phosphino^[10] groups have been silylated with hydrosilanes as silicon source and Ir or Ru-based catalysts (Scheme 1B.a). In fact, a catalytic undirected $C(sp^3)$ -H silylation of methylarenes has yet to be developed, though isolated examples

A. State-of-the-art stoichiometric benzylic silylation

Scheme 1. Benzylic $C(sp^3)$ —H bond silylation reactions.



have been reported using a homogeneous (Scheme 1B.b)^[11] or a heterogeneous^[12] transition metal-free catalytic system.

Herein, we describe for the first time a transition metalfree catalytic protocol for the undirected silvlation of benzylic $C(sp^3)$ -H bonds with easy-to-access and thermally stable tert-butyl-substituted silyldiazenes (tBu-N=N-SiR₃, Scheme 1C). We have shown previously that the latter reagents promote the C(sp2)-H bond silylation of weakly acidic (hetero)aryl compounds such as indoles or fluoroarenes upon treatment with a catalytic amount of Brønsted bases.[13] In particular, we noticed that when 1,4-dimethylindole 2 was reacted with diazene 1a (1.2 equiv) and tBuOK (10 mol %), the expected C2-silylated products was produced in good yields along with minor amounts of a $C(sp^3)$ –SiEt₃ containing byproduct. The latter was unambiguously identified through the marginal modification of these reaction conditions (3.5 equiv 1a and 20 mol % tBuOK) that allowed to cleanly isolate the benzylsilane 2a₂ in 82 % yield (Equation (1) below). 2a₂ arises from the innate silvlation of the methyl $C(sp^3)$ -H bond, which in this case is slower than the C₂-silylation event yet kinetically accessible without any directing group. This observation prompted us to study such an unprecedented silylation pathway with unactivated methylarenes.

Results and Discussion

We began our investigations by selecting 4-methylanisole 3 as a model substrate because the selective functionalization of the benzylic α -position by conventional stoichiometric metalation approaches has only been met with little success despite tremendous research effort. For example, metalation with nBuLi/TMEDA followed by anion-trapping with Me₃SiCl afforded almost exclusively the silylated product arising from the directed *ortho* metalation (DoM) rather

than the α -silylated (laterally-silylated) one.^[15] With this in mind, we reacted **3** with triethylsilyl-substituted diazene **1a** (1.2 equiv) and tBuOK (10 mol%) as a catalytic promoter (entry 2, Table 1) in THF (0.14 M). While these conditions proved successful for the silylation of $C(sp^2)$ —H bonds,^[13] only modest yield and selectivity were observed as benzylsilane **3a** was formed in 36% yield alongside the *ortho*-silylated anisole **3a**′ (24%) and the bis-silylated product **3a**₂ (ca. 8%) formed by both lateral and *ortho* silylation.

Subsequent optimization of the reaction parameters (see Table 1 and Table S1 in the Supporting Information for details) revealed that both productive (>95 % conversion) and selective (>81 % 3a) lateral silylation could be achieved by dropping neat more than 2 equiv of diazene 1a while using THF as solvent and a potassium salt as catalyst (entries 1 and 3-4 in Table 1). Under the optimal conditions (2 equiv 1a and 10 mol % tBuOK), the benzylsilane 3a could be isolated in 84 % yield after chromatography. This result is striking as 3 had thus far resisted selective lateral silylation. For example, when hydrosilanes were used as silicon sources in conjunction with catalytic amount of tBuOK[11] or a calcium benzyl complex, [16] only the arylsilane 3a' was obtained. Similarly, using O'Shea's benzylic silylation protocol that we carried out for the sake of comparison, 3a' was still the major product formed at the expense of 3a (7% yield, entry 5 in Table 1), though this strategy constitutes one of the best option available for challenging lateral metalation/functionalization. With diazene 1a as silicon source, such a selectivity reversal could be achieved simply by replacing tBuOK with its sodium counterpart (entry 6, Table 1). As an illustration, the ortho-silvlated anisole 3a' was formed in 64% yield along with only 7% of 3a after 30 h of reaction with 20 mol % tBuONa. The previously elusive $C(sp^3)$ —H silylation of 3 or its *ortho*-silylation may therefore be selectively selected by changing the nature of the cationic part of the catalytic system.

The generality of the $1a/KOtBu_{cat}$ system to achieve undirected benzylic $C(sp^3)$ —H silylation selectively was further probed with various methylarenes. The *meta* and *ortho* isomers of 3 reacted smoothly (99 % and 87 % isolated yield, respectively) with nearly complete selectivity for lateral silylation. The latter site selectivity contrasts sharply with the reported rhodium-catalyzed dehydrogenative silyla-

Table 1: Optimization of the silylation of 4-methylanisole.

	MeO 3 1a (0.1 mmol) (2.0 eq.) 3a (3a) (3a) (4a) (4a) (4a) (4a) (4a) (4a) (4a) (4			
Entry	Deviation	ho	Yield 3 a	$3 a/3 a'/3 a_2$
1	none	98	81 (84) ^[a]	81/5/14
2	1.2 equiv 1 a , ^[b] THF (0.14 M)	77	36	53/35/12
3	KOH (10 mol%), 30 h	44	28	75/21/4
4	Me ₃ SiOK (10 mol%)	97	82	83/5/12
5 ^[c]	nBuLi (1.2 eq), $tBuOK$ (1.2 equiv), TMP (1.0 equiv) 15 min, then Et ₃ SiCl (3.0 equiv)	88	7	10/77/13
6	tBuONa (20 mol%), 30 h	80	64 (3 a')	9/81/10

Conversion (ρ), yield and selectivity [all %] determined by calibrated GC (gas chromatography) using n-tetracosane as an internal standard. [a] Isolated yield. [b] 1a added dropwise in solution. [c] O'Shea's protocol^[6b] conducted on 1.0 mmol scale of a. TMP=2,2,6,6-tetramethylpiperidine.

Scheme 2. C(sp³)—H silylation of methylarenes. Reaction conditions: alkylarene (0.5 mmol), 1a (3.0 equiv), tBuOK (10 mol%) and THF (0.5 mL, 1 M) at RT. Yields refer to those of purified isolated products. [a] NMR yield of product obtained following O'Shea's stoichiometric protocol (c.f. entry 5 in Table 1). [b] 20 mol% tBuOK. [c] 20 mol% tBuOK, 0.14 M. [d] 10 mol% tBuOK and 3.0 equiv 1a. [el 40 mol% tBuOK, 3.0 equiv 1a, 0.01 M, 1.5 h. TBS = tert-butyldimethylsilyl.

tion reactions that exclusively take place on the arene ring of these substrates.^[17] Beyond the methoxy group, other electron-releasing groups were well-tolerated in the reaction, such as potentially directing phenoxy (6-7), TBSprotected hydroxyl (8), amino (9-10) and diphenylphosphino (11) substituents or two meta-located bulky tert-butyl groups (12). Importantly, the N-H bond in 10 was welltolerated as it was first in situ silylated before being deprotected upon purification to afford **10a** in 87 % yield. In all instances, the mono-silylated benzylsilanes arising from the *undirected* $C(sp^3)$ –H silvlation were largely major over the potentially competing arylsilanes or the mixed sp^2/sp^3 bis-silvlated products. As an illustration, while the 2phenoxybenzylsilane 6a was isolated in 92% yield with nearly complete lateral selectivity, the meta isomer 7a (60 % yield) was accompanied by ca. 14 % of separable sp^2/sp^3 bissilylated product.

Slightly electron-withdrawing substituents (Ph, vinyl and alkynyl) were also tolerated, even when the benzylic position is hindered by a rigid Ph group in the ortho position as in product **14a** (69 % yield). Importantly, the benzylsilanes **15a** and **16a** bearing TBS-substituted vinyl and alkynyl moieties were isolated in 61 % and 88 % yield with

untouched π -bonds that would readily undergo hydrosilylation with hydrosilanes. In contrast, the reaction of methylarenes bearing strongly electron-withdrawing cyano or nitro groups in the *para* position gave almost no desired benzylsilanes. Nonetheless, less aromatic methylarenes such as 1- and 2-methylnaphtalene (17–18) and electron-deficient 4-methylpyridine (19) afforded good to excellent yields of the desired silanes 17–19 a.

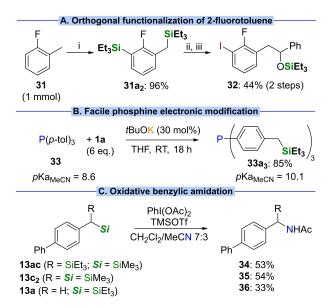
Toluene or its perdeuterated congener that display no electronic nor steric bias reacted in a very efficient manner with diazene ${\bf 1a}$ affording ${\bf 20a}$ and ${\bf 20a}$ - ${\bf d_7}$ in 78% and 90% isolated yield, respectively. This result contrasts sharply with the 24% yield of ${\bf 20a}$ obtained with the Grubbs-Stoltz reagent (Et₃SiH/KOtBu_{cat}) after 108 h at 65 °C. [11] The enhanced productivity of the ${\bf 1a}$ /KOtBu_{cat} pair was further established with substrates displaying comparatively higher steric bulk at the benzylic position, such as ethylbenzene ${\bf 21}$ and some benzyl(thio)ethers. In all cases, the benzylsilanes ${\bf 21}$ - ${\bf 24a}$ were isolated in good to excellent yields, with only marginal change of the reaction conditions needed in the case of ethylbenzene (dilute reaction medium).

To put the above-described reaction scope into perspective, we further set out to compare it with O'Shea's





Scheme 3. Silyl group influence (A) and *gem*-disilanes synthesis (B). [a] Yields refer to those of purified isolated products but those for **13 c–e** were determined by ¹H NMR spectroscopy using 1,3,5-trimethoxybenzene as internal standard.



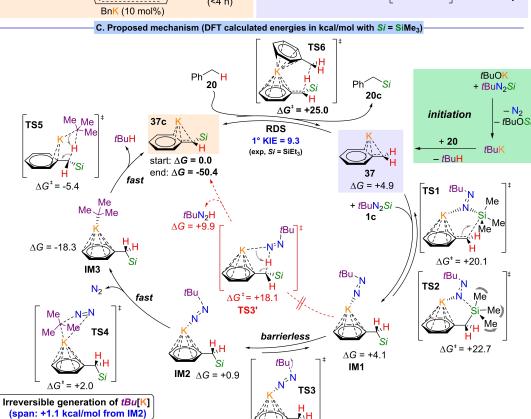
Scheme 4. Applications. A. i: **1a** (6 equiv), tBuOK (20 mol%), RT, 4 h. ii: ICl (1.1 equiv), RT, 13 h, 78% iii: PhCHO (1.2 equiv), Me $_3$ SiOK (20 mol%), NBu $_4$ Cl (20 mol%), RT, 21 h, 56%. B: p K_a 's in MeCN were determined by DFT calculations and relate to the Ar $_3$ PH $^+$ /Ar $_3$ P couples.

stoichiometric benzylic silylation protocol^[6b] for a handful of previously-unreported examples (yields within square brackets on Scheme 2). Specifically, the **1a**/KOtBu_{cat} system not only allows catalytic-in-metal benzylic silylations under noncryogenic conditions, but also performs clearly better in terms of activity and/or selectivity on substrates such as

methylarenes with an electron releasing group in the para position (e.g. 3, 9 & 10), those bearing a hindered benzylic position (e.g. in 6 & 14) or arylbenzylethers (23). In the same vein, one-step silvlation of multiple benzylic positions in substrates such as dimethylbenzene (xylene) derivatives remains largely out of reach of stoichiometric metalation/ silvlation sequences because of the instability of the corresponding poly-benzylanions. In contrast, the exhaustive silvlation of the meta (25) and para (26) isomers of xylene was easily achieved using **1a** (6 equiv) and 20 mol % tBuOK, though o-xylene mostly afforded the mono-silylated product 27a (Scheme 2D). Importantly, the bis-silylation process tolerates a chloride, a fluoride or an ester substituent at the 2-position of m-xylene that were barely compatible in the corresponding mono-methylarenes for reactivity (Cl, CO2tBu) or selectivity (F, vide infra) reasons. In the case of the benzoate 30, the steric hindrance favored the monosilvlation product (30a, 56% yield) and the reaction conditions had to be slightly modified to avoid its decomposition in the reaction medium.

Beyond the Et₃Si group, we also studied the transfer of other silvl groups from the corresponding diazenes 1b-e to 4-methylbiphenyl 13 (Scheme 3A). The bulky Me₂tBuSi group was transferred cleanly albeit more slowly (63% isolated after 16 h). In contrast, the benzylsilanes 13c-e bearing Me₃Si, Me₂PhSi and *i*Pr₂HSi groups were rapidly formed yet were all contaminated with the corresponding homoleptic gem-disilanes that could be isolated in the case of 13c2 and 13c2 simply by increasing the amount of 1c or 1e. Because such disilanes were not formed with excess 1a or 1b, we also showed that the heteroleptic gem-disilanes bearing Me₃Si/Et₃Si (13ac), Me₃Si/Me₂tBuSi (13bc) and HiPr₂Si/Et₃Si (13 ae) groups can be prepared with one-pot procedures by adding first the bulkier diazene followed by the less hindered one (see the Supporting Information for details). Such a control over the mono vs. bis-silylation pathways that arises from the fine tuning of the steric hindrance of the silvl group contrasts sharply with the related benzylic C-H borylation protocols that exclusively deliver unstable bis-boronate species.^[18] Hence, the present methodology offers an alternative synthesis of benzylic geminal bis-silane compounds that were pioneered by Snieckus^[19] and that have recently been prepared by repeated metalation/silylation sequences[2d] or by Pd-catalyzed cross-coupling[20] and carbene insertion into Si-Si bond.[21]

We next sought to illustrate one aspect of the synthetic potential of the present methodology in that it allows to easily produce polysilylated compounds on both sp^2 and/or sp^3 centers so as to readily increase molecular complexity from cheap and widely available starting materials. At the outset, we reacted 2-fluorotoluene 31 with excess diazene 1a. As expected, we deliberately obtained the bis-silylated compound 31a₂ in 96% yield that contains two C–SiEt₃ bonds displaying different reactivity that can be exploited in orthogonal synthetic downstream functionalization (Scheme 4A). In this respect, the arylsilane moiety of 31a₂ was first converted into the corresponding iodide by *ipso* substitution and the resulting benzylsilane was reacted with



Scheme 5. Experimental (A and B) as well as computational (C) mechanistic investigations. Gibbs free energies ($kcal \, mol^{-1}$) were calculated at the B3LYP-D3(PCM = THF)/Def2TZVP//B3LYP-D3(PCM = THF)/6-31 + G(d) level of theory. RDS = rate determining step; KIE = kinetic isotope effect.

benzaldehyde to afford the Et₃Si-protected secondary alcohol 32 in 56% isolated yield. [6b] Beyond organic synthesis, the polysilylation strategy also enables the facile modification of tri(p-tolyl)phosphine 33 widely used as ligand in homogeneous catalysis (Scheme 4B). The three-fold silylation of 33 afforded the novel triarylphosphine 33a, (85% yield within 18 h) in which the three -CH₂SiEt₃ group greatly enrich the P atom as a result of strong σ - π hyperconjugation. As a consequence, $33a_3$ displays σ -donating properties similar to those of tri(p-anisyl)phosphine as witnessed by the relative pK_a 's of the corresponding phosphoniums (10.1 vs. 10.2 for $(4-MeOC_6H_4)_3PH^+$ in MeCN) that correlate to the Tolman's electronic parameters.[22]

The last illustration involves electron rich homo- and heteroleptic *gem*-disilanes, which we surmised could undergo oxidative functionalization, though tetraalkylsilanes (including benzyltrialkylsilanes) are generally considered unreactive towards common oxidants (Scheme 4C).^[23] Inspired by a recent report from Shafir and Cuenca,^[24] we reacted

13ac and 13c₂ with TMSOTf-activated PhI(OAc)₂ at low temperature and obtained the new α -silylated benzylacetamides 34 and 35 that still contain a potentially reactive C–Si bond in 53% and 54% yield respectively. In the case of 13ac, the C–SiMe₃ bond was preferentially cleaved over the C–SiEt₃, though the latter was not deemed oxidatively unbreakable (13a \rightarrow 36).

Finally, we investigated the mechanism of the reaction between toluene 20 and diazene 1a with the goal in mind to delineate the fate of the potassium cation initially bound to the *tert*-butoxide anion. At the outset, a careful monitoring of the catalytic silylation of 20 with 1a triggered by 10 mol % tBuOK revealed that all the potassium is stored in the α -silylated benzylpotassium 37a that acts as the resting state of the catalysis (Scheme 5A). 37a was the only intermediate observed by NMR spectroscopy irrespective of the reaction conversion. Importantly, independently synthesized benzylpotassium (BnK, 37, 10 mol %) also catalyzes the silylation of 20 (and of 4-methylanisole 3) with similar activity, selectivity and resting state identity (37a) than the

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much less basic tBuOK. As a consequence, the latter alkoxide likely plays the role of anionic initiator that ultimately generates catalytically-competent BnK upon reaction with diazene 1a in the presence of toluene. In fact, trapping experiments with electrophilic carbanion scavengers strongly suggests that tert-butylpotassium (tBuK) is rapidly formed upon reaction of tert-butyl-substituted silyldiazenes with tBuOK (see section 4.6 in the Supporting Information). [25] As such, the initiation step furnishes BnK through the metalation of toluene 20 with tBuK (top right corner in Scheme 5C).

Fully in line with the catalytic observations, the stoichiometric reaction of the thus-generated BnK with 1a (1 equiv) in THF- d_8 at room temperature rapidly afforded 37a (Scheme 5B), structure of which was ultimately confirmed by its independent preparation from BnK and benzyltriethylsilane 20 a. This result demonstrates that (i) 37 preferentially reacts with the silyl group of diazene 1a to afford BnSiEt₃ 20a and that (ii) the latter species was the most acidic present in the reaction medium as most of the potassium is "stored" in the conjugate base 37a. It also indicates that the diazene decomposition upon reaction with BnK generates highly basic species well poised to metalate

To shed light on the experimentally-elusive intermediates generated by the decomposition of tert-butyl-substituted silyldiazenes with catalytically-competent BnK 37, we con-DFT calculations (B3LYP-D3(PCM=THF)/Def2TZVP//B3LYP-D3(PCM=THF)/6-31+G(d)) with 1c as a model diazene (Scheme 5C and Figure S6 in the Supporting Information). First, the initiation pathway furnishes 37 from tBuOK, 20 and 1c. The catalytic cycle then begins with the facile formation of the C-Si bond from 37 and 1c through TS1 followed by the collapse of the silicate (not shown) into the potassium diazenyl intermediate IM1 upon Berry-pseudorotation and N-Si dissociation (TS2). The singly-bent diazenyl moiety in IM1 further evolves by denitrogenation through a rapid two-step process (IM1→IM3). First, a barrierless elongation of the C–N bond between the tBu and N=N units leads to the weakly bound diazenyl complex IM2 ($d_{\rm N=N}\!=\!1.18~{\rm \AA}$ vs. 1.21 ${\rm \AA}$ in IM1 and $1.10\,\text{Å}$ in N_2) through TS3. IM2 then undergoes an irreversible denitrogenative β -carbon elimination to generate the η^6 -arene tert-butylpotassium complex IM3. The extremely low barrier $(+1.1 \text{ kcal mol}^{-1} \text{ for } \mathbf{TS4} \text{ from } \mathbf{IM2})$ that needs to be overcome to obtain such a reactive intermediate is remarkable, yet fully intelligible owing to the high stability of N₂. A concerted metalation deprotonation (CMD) of one of the benzylic C-H bonds with tBu as base subsequently takes place via **TS5** $(+12.9 \text{ kcal mol}^{-1} \text{ from})$ IM3) to yield the α -silvlated benzylpotassium 37c. An alternative pathway for the generation of the latter species directly from IM1 was uncovered, in which the CMD occurs with the tBuN₂ unit. However, not only is this step endergonic but the associated computed barrier (TS3', 14.0 kcalmol⁻¹ from **IM1**) is also much higher than the ones obtained for the irreversible denitrogenative pathway (IM1 - IM3). As a consequence, the tert-butylpotassium complex IM3 is the true metalating agent involved in the

formation of 37c from 37 and 1c that overall proceeds rapidly with a barrier of 17.9 kcal mol⁻¹ (TS₂) and quantitively $(\Delta G = -55.2 \text{ kcal mol}^{-1} \text{ for } 37 + 1 \text{ c} \rightarrow 37 \text{ c} + \text{N}_2 + t \text{BuH}).$

In agreement with the experimentally verified resting state identity, 37c is the lowest-in-energy intermediate on the potential energy surface (and thus the origin of all relative energies in Scheme 5C). Under the catalytic conditions, it is also the direct precursor of the desired benzylsilane through protonation with toluene. In line with the accumulation of 37a in the reaction medium, this step is rate limiting (TS6, 25 kcalmol⁻¹) and regenerates BnK that further sustains catalytic turnovers upon reaction with 1c. As far as Et₃Si-substituted diazene 1a is concerned, the observation of a strong primary kinetic isotope effect (KIE) of 9.3 by evaluating the relative rate of reaction of toluene and toluene- d_8 further supports such a view. [26]

Conclusion

To conclude, we have disclosed the first general, catalytic-inmetal and undirected silvlation of benzylic $C(sp^3)$ -H bonds that allows to selectively prepare both mono- or gem-bis benzyl(di)silanes under ambient, transition metal-free conditions. The high activity and selectivity of the 1a/KOtBu_{cat} combination towards benzylic silylation originates from the facile generation of organopotassium reagents that proved highly selective for lateral metalation compared to their lighter congeners (Na or Li). Both experimental and computational mechanistic studies point to the facile, steady-state generation of tert-butylpotassium that further sustains an anionic chain reaction in a tamed way. As such, the anionic decomposition of tert-butyl-substituted silyldiazenes brings a new solution to the metalation of weakly acidic benzylic C-H bonds with s-block-based polar organometallics.[27]

Acknowledgements

We thank Sorbonne Université and CNRS for financial support and F. Lucien for an early contribution to this work. C.C. gratefully acknowledges the French Agence Nationale de la Recherche for a grant (ANR-21-CE07-0031). Calculations have been performed using the high-performance computing (HPC) resources of the service d'aide au calcul et à l'analyse de données (SACADO) at MeSU platform at Sorbonne Université.

Conflict of Interest

The authors declare no conflict of interest.

Data Availability Statement

The data that support the findings of this study are available in the Supporting Information of this article.

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Keywords: C—H Functionalization · Diazene · Metalation · Organopotassium · Silylation

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Manuscript received: May 2, 2023 Accepted manuscript online: June 6, 2023 Version of record online: June 26, 2023